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Huge electron-hole exchange interaction in aluminum nitride

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Optical spectroscopy is performed for c-plane homoepitaxial aluminum nitride (AlN) films. The temperature dependence of the polarization-resolved photoluminescence spectra reveals the exciton fine structure. The experimental results demonstrate that the electron-hole exchange interaction energy \( j \) in AlN is \( j = 6.8 \text{ meV} \), which is the largest value for typical III-V and II-VI compound semiconductors. We propose the effective interatomic distance as the criterion of the electron-hole exchange interaction energy, revealing a universal rule. This study should encourage potential applications of excitonic optoelectronic devices in nitride semiconductors similar to those using II-VI compound semiconductors.

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Excitons, which are a type of fundamental excitation in crystals, dominate optical transitions in semiconducting materials at low temperatures. In wide band-gap materials, such as oxide or nitride semiconductors, an exciton may exist up to room temperature due to its small Bohr radius. Consequently, excitonic effects have been extensively studied in oxide semiconductors toward realizing, for example, low-threshold lasing. However, in nitride semiconductors, the impact of excitonic effects on the performance of optoelectronic devices has not been considered explicitly. This is partly because the relatively poor crystalline quality hinders the intrinsic exciton physics, and essentially because the excitonic correlations in GaN are weak compared with those in ZnO. One gauge of the excitonic interaction is the electron-hole exchange interaction energy \( j \), which is estimated to be 1.2 meV and 5.8 meV in GaN and ZnO, respectively. This is why an excitonic nature has yet to be observed in current GaN-based optoelectronic devices, such as blue light-emitting diodes or green laser diodes.

Recently, aluminum nitride (AlN) has realized a new frontier of nitride semiconductor optoelectronic technology into the deep ultraviolet spectral region due to its distinguished properties. The band gap \( E_g \) is 6.0 eV. The exciton Bohr radius and the exciton binding energy of AlN are \( \sim 1.5 \) nm and \( \sim 53 \) meV, respectively. These values are comparable to those of ZnO. Consequently, huge excitonic correlations should exist in AlN. To date, the electron-hole exchange interaction in AlN has been studied in only one work and is estimated to be \( j = -4.0 \text{ meV} \). However, if the sign of \( j \) is negative, a spin-triplet exciton is energetically higher than a spin-singlet exciton, which contradicts the results of both solid state physics within a framework of a simple two-band approximation and previous experiments on any other semiconducting materials. Therefore, the electron-hole exchange interaction in AlN should be examined in detail.

In this study, photoluminescence (PL) spectroscopy is performed on state-of-the-art c-plane homoepitaxial AlN films. The temperature dependence of the polarization-resolved PL spectra reveals the exciton fine structure. The experimental results indicate that in AlN the electron-hole exchange interaction energy \( j \) is 6.8 meV, which is the largest value among typical III-V and II-VI compound semiconductors. We propose that as a universal rule, the effective interatomic distance is a criterion of \( j \).

Homoeptaxial AlN films are grown by metal-organic vapor phase epitaxy on the c-plane AlN bulk substrates prepared by a physical vapor transport method. The x-ray rocking curves of (0002) symmetric and (1102) asymmetric planes for the epilayer are 14 and 29 arcsec, respectively. The carbon concentration in the epilayer is below the detection limit of secondary ion mass spectroscopy, which is \( <3 \times 10^{17} \text{ cm}^{-3} \). The oxygen and the silicon concentrations are near the detection limit of \( 6 \times 10^{17} \text{ cm}^{-3} \) and \( 1 \times 10^{16} \text{ cm}^{-3} \), respectively. The results indicate that homoeptaxial AlN films have excellent crystalline qualities. Pretreatment of the substrate and growth conditions are detailed elsewhere.

PL spectroscopy is performed for the c-plane homoeptaxial AlN films using a pulsed ArF excimer laser (\( \lambda = 193 \) nm). The repetition rate and the pulse width are 25 Hz and 4 ns, respectively. The PL signals are dispersed by a 50 cm monochromator with a LN2-cooled charge-coupled device. The spectral resolution is about 0.045 nm at a wavelength of 200 nm, which corresponds to about 1 meV. The temperature dependence is measured using a closed-cycle cryostat from 10 to 300 K. Herein, we carry out PL spectroscopy under two experimental configurations. In Config. (a), the sample is excited from the surface normal, and the PL signal is detected at an angle of 60° with the surface normal. In Config. (b), the PL signal of a sample is detected from the surface normal, and the sample is excited at an angle of 60° with the surface normal.

Before describing the experimental results, the electronic band structure of AlN should be recalled. The conduction and valence band edges are assumed to be composed of the atomic \( s \) orbital and \( p \) orbital, respectively. The 1s excitonic effective Hamiltonian in wurtzite crystals is derived by the theory of invariants as

\[
H = \Delta_1 J_z^2 + \Delta_2 J_z \sigma_{\perp z} + \Delta_3 (\sigma_{+v} J_z + \sigma_{-v} J_z) + \frac{1}{2} J \sigma_e \sigma_h, \tag{1}
\]

where \( \Delta_1 \) is the crystal-field split interaction energy, and \( \Delta_2, \Delta_3 \) are the parallel (\( \parallel \ c \) ) and perpendicular (\( \perp \ c \) ) components of the spin-orbit interaction energy. \( J \) is an electron-hole exchange interaction energy, which is the subject in this paper. The other notations in Eq. (1) are the same as those in Ref. 7. Numerous works have investigated \( \Delta_1-3 \) in AlN. These studies have revealed a negatively large \( \Delta_1 \) and a positively small
The center diagram in Fig. 1 shows the electronic band structure of AlN. From low to high electron energy, the valence band ordering in AlN is $\Gamma_7^v - \Gamma_9^v - \Gamma_7^v$. As already mentioned, a negative electron-hole exchange interaction energy in AlN has been reported. If the sign of $j$ is negative, the exciton fine structure of AlN is represented as the left diagram in Fig. 1. On the other hand, if the sign of $j$ is positive, the exciton fine structure is represented as the right diagram in Fig. 1. The oscillator strength of $\Gamma_1^A$ is much smaller than that of $\Gamma_1^A$ in both the cases. Figure 1 suggests that the sign of $j$ can be estimated by the energy ordering of $\Gamma_1^A$ and $\Gamma_5^A$.

Figure 2 shows a typical PL spectrum for our $c$-plane homoepitaxial AlN films taken under a weak excitation condition at 10 K with the experimental geometry of Config. (a). Several sharp peaks are observed, which are called $D^0X$, $X$, $\alpha$, and FX, in this paper. Neuschl et al. suggested that the origin of the $D^0X$ peak is a silicon donor-bound exciton. The $\alpha$ peak has not been identified. The thermal behavior of the FX peak located at a higher energy unambiguously indicates the free excitonic nature. Although the X peak has been assigned to the bound state of impurities, this assignment remains debatable due to polarization properties. Our previous work demonstrated that the luminescence peaks of $D^0X$ and FX are polarized parallel to the $c$ axis ($E \parallel c$) while the luminescence peak of X is polarized perpendicular to the $c$ axis ($E \perp c$). The origin of the FX peak is identified as $\Gamma_1^A$, but a simple shallow bound exciton picture cannot account for the observed polarization of the X peak.

In this paper, we identify the origin of the X peak by the temperature dependence of the polarization-resolved PL spectra for $c$-plane homoepitaxial AlN films. Figures 3(a) and 3(b) show the temperature-dependent PL spectra with the experimental geometry of Config. (a) and (b), respectively. The PL spectra are rather different from that of Fig. 2 due to the excitation power density. In Fig. 3(a), the free excitonic nature of the FX peak is clearly observed, while in Fig. 3(b), the luminescence of the X peak is observed up to room temperature despite the 13.6 meV energy difference between the X and FX peaks. The X peak does not seem to be a bound state of the FX peak. Hence, the temperature dependence of the PL integrated intensity is quantitatively estimated for each peak by the following equation:

$$I(T) = I(0)/[1 + A \exp \left(-E_a/k_BT\right)],$$

where $E_a$ and $k_B$ are the thermal activation energy and Boltzmann constant, respectively. A characterizes the oscillator strength of a peak. The thermal activation energies of $D^0X$, X, and FX are estimated to be 6.4 meV, 42 meV, and 46 meV, respectively (Fig. 4). The activation energy of the X peak is much larger than the energy difference between the peaks of X and FX (13.6 meV). Furthermore, the activation energy is nearly the same as the free exciton binding energy derived from the effective mass approximation. Therefore, we conclude...
TABLE I. Material parameters in typical III-V and II-VI compound semiconductors. Unless stated, those in nitride semiconductors are picked up from Ref. 25, while in others are picked up from Ref. 26.

<table>
<thead>
<tr>
<th>Materials</th>
<th>$E_g$ (eV)</th>
<th>$a$ (Å)</th>
<th>$c$ (Å)</th>
<th>$u$</th>
<th>$\epsilon$</th>
<th>$\epsilon_\perp$</th>
<th>$\epsilon_\parallel$</th>
<th>$j$ (meV)</th>
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<tr>
<td>ZnS (ZB)</td>
<td>3.84</td>
<td>5.4053</td>
<td></td>
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<td>8.3</td>
<td></td>
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<td>4.0 (Ref. 8)</td>
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<td>ZnSe (ZB)</td>
<td>2.82</td>
<td>5.6674</td>
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<td>8.6</td>
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<td>1.0 (Ref. 8)</td>
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<td>6.0882</td>
<td></td>
<td></td>
<td>10.3</td>
<td></td>
<td></td>
<td>0.28 (Ref. 21)</td>
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<tr>
<td>GaP (ZB)</td>
<td>2.350</td>
<td>5.45064</td>
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<td></td>
<td>11.1</td>
<td></td>
<td></td>
<td>0.175 (Ref. 27)</td>
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<td>CdTe (ZB)</td>
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<td></td>
<td>10.4</td>
<td></td>
<td></td>
<td>0.07 (Ref. 28)</td>
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<td>GaAs (ZB)</td>
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<td></td>
<td>12.8</td>
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<td></td>
<td>0.015 (Ref. 29), 0.075 (Ref. 30)</td>
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<td>AlN (WZ)</td>
<td>6.10</td>
<td>3.112</td>
<td>4.982</td>
<td>0.3819 (Ref. 34)</td>
<td>7.8 (Ref. 35)</td>
<td>9.3 (Ref. 35)</td>
<td>6.8 (This work)</td>
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<tr>
<td>GaN (WZ)</td>
<td>3.51</td>
<td>3.189</td>
<td>5.145</td>
<td>0.3772 (Ref. 34)</td>
<td>9.3 (Ref. 36)</td>
<td>10.1 (Ref. 36)</td>
<td>1.2 (Ref. 7)</td>
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<tr>
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<td>3.2496</td>
<td>5.2042</td>
<td>0.3807 (Ref. 34)</td>
<td>7.8</td>
<td>8.8</td>
<td>5.6 (Ref. 8), 4.9 (Ref. 31), 4.73 (Ref. 32)</td>
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<tr>
<td>CdS (WZ)</td>
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<td>6.7490</td>
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<td>7.0109</td>
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<td>9.3</td>
<td>10.2</td>
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FIG. 4. (Color online) Arrhenius plots of each peak, $D^\ddagger$X, X, and FX.

that the X peak originates from the free exciton with an irreducible representation of $\Gamma_4^\perp$. This interpretation can also readily explain the aforementioned optical polarization property of the X peak ($E \perp c$). The energy ordering of $\Gamma_4^\perp$ and $\Gamma_3^\perp$ indicates that the electron-hole exchange interaction energy in AlN has to be positive (right diagram in Fig. 1), and is estimated to be $j \approx 6.8$ meV by Eq. (1). The larger thermal quenching of the X peak is consistent with the theoretical prediction of a much smaller oscillator strength. It should be noted that our interpretation is also consistent with the results of reflectance spectroscopy for AlN bulk substrates under uniaxial stress.

The origin of the $\alpha$ peak should be discussed considering the aforementioned results. The donor binding energy in AlN is estimated to be $\approx 60$ meV via the effective mass theory. Applying the Hayne’s rule of GaN to AlN, the binding energy is estimated to be $\approx 12$ meV. This value is nearly the same as the energy difference between the peaks of FX and $\alpha$ (9.5 meV). Therefore, we suggest that the $\alpha$ peak originates from the donor bound exciton of the FX peak.

Above, the electron-hole exchange interaction is experimentally studied in AlN. Below, we discuss the value of $j$ in typical III-V and II-VI compound semiconductors.

Rohrer showed that $j$ is about 10–20% of the exciton binding energy in II-VI compound semiconductors and is correlated with $\epsilon/(\mu a)^2$, where $\epsilon$, $\mu$, and $a$ are the dielectric constant, the exciton reduced-mass, and the lattice constant, respectively. Wardzyński et al. demonstrated that $j$ is correlated with the interatomic distance.19 Julier et al. expanded the interpretation to GaN.20 Fu et al. suggested that $j$ is correlated with the exciton Bohr radius.21 However, the methods proposed in Refs. 20 and 23 are not applicable to anisotropic materials and uncertainties about the choice of hole mass remain. The method proposed in Refs. 21 and 22 can explain the behavior only in common-anion (cation) materials. Therefore, another gauge that can universally explain the value of $j$ in any semiconducting materials should be established.

Here, we treat the exchange interaction problem between an electron and a hole under the Hartree-Fock approximation. The effective mass approximation is assumed to describe the materials. Therefore, another gauge that can universally explain the value of $j$ in any semiconducting materials should be established.

The effective mass approximation is assumed to describe the electron-hole exchange interaction. Here, we treat the exchange interaction problem between an electron and a hole under the Hartree-Fock approximation. The effective mass approximation is assumed to describe the electron-hole exchange interaction. Here, we treat the exchange interaction problem between an electron and a hole under the Hartree-Fock approximation.
parameter, respectively. Therefore, we propose an effective interatomic distance \( d_{\text{eff}} \) as a gauge of the electron-hole exchange interaction energy as
\[
d_{\text{eff}}^{\text{WZ}} = \sqrt{\left(2\epsilon_{\perp}d_{\perp}^2 + \epsilon_{\parallel}d_{\parallel}^2\right)/3}.
\]
Table I summarizes the material parameters in typical III-V and II-VI compound semiconductors. Figure 5 shows the relationship between \( d_{\text{eff}} \) and \( j \). The value of \( j \) can be characterized by \( d_{\text{eff}} \), which strongly supports the result in this paper of \( j = 6.8 \text{ meV} \) in AlN.

In conclusion, the electron-hole exchange interaction energy is experimentally demonstrated to be \( j = 6.8 \text{ meV} \), which is the largest value among typical III-V and II-VI compound semiconductors. It should be noted that \( j \) is a crucial parameter to understand the excitonic properties in wide band-gap materials, and for example, is related to an open problem on the valence band ordering in ZnO. As a gauge of the electron-hole exchange interaction energy, the effective interatomic distance \( d_{\text{eff}} \) is proposed.

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39 The valence band ordering in ZnO is out of the scope of this paper.